Birefringence Properties and Surface Relief Grating Formation on Methylacrylate Polymers with Photochromic Side Chains

S. Ahmadi-Kandjani, P. Tajalli, H. Khoshsima, R. Barille, J.-M. Nunzi, S. Kucharski, and H. Tajallia,b

aResearch Institute for Applied Physics and Astronomy, University of Tabriz, Iran
bFaculty of Physics, University of Tabriz, Iran
cLaboratoire POMA, Université d’Angers, Angers, France
dDepartment of Chemistry, Chernoff Hall, Queen’s University, Canada
eWroclaw University of Technology, Faculty of Chemistry, Department of Polymer Engineering and Technology, Wroclaw, Poland.

Abstract- We have studied light-induced birefringence (LIB) and surface relief grating (SRG) formation in the series of methylacrylate polymers. The effect of material structure such as length of photochromic side chain, glass transition temperature and molecular structure of azo units on LIB and SRG are studied. The optical formation of self-induced SRG on films of these materials is also presented.

KEYWORDS: Surface relief grating, light-induced birefringence, methylacrylate polymers, photoisomerization

I. INTRODUCTION

Surface relief gratings (SRG) manufactured by the holography technique in azo-polymers have recently found wide utilisation and their areas of application are constantly widening. SRG can be used as couplers (wave-guide input-output elements), filters, polarization separators, liquid crystal orientation, holographic data storage, waveguides, etc. [1-5].

The main interest of azo-polymers for the SRG formation is due to their dichroic and birefringent properties when they are illuminated by a polarized light. This behavior is because of a reversible "trans-cis" photoisomerization with respect to the N=N double bond and redistribution in the orientation of the azo dye molecules (perpendicular to the polarization direction of light) [6].

Following to this photoisomerization cycles, the large-scale mass transport of the azo polymer chains occurs by moving from bright to dark region of interference pattern, which results modulation of surface in a reversible way. Several mechanisms by various research groups have been proposed to explain SRG formation in azo-polymers [7-11].

In order to understand the mechanism of SRG formation and to design high-performance SRG-forming materials (photoprocessability and photoresponse behaviour), it is necessary to elucidate the relationship between molecular structure and SRG formation.

Different classes of azobenzene polymers including polymeric matrices, such as epoxy, polyacrylates, liquid-crystalline polyesters, azo hybrid gel films, polyurea and conjugated polymers such as polydiacetylene and polyacetylene have been used for SRG formation [12–18]. These materials can be in the form of both side chain as well as main chain azo-polymers. The recorded SRGs are stable below the glass transition temperature Tg, and can be erased optically. SRGs are strongly depended on the polarization and the energy of the recording beams.

Spontaneous hexagonal structure has been formed on the surface of an azo-polymer by illuminating the polymer film with a linearly polarized laser beam. The elongation direction...
of the hexagons depends on the polarization direction of the laser beam [19].

We have recently demonstrated that spontaneous periodic SRGs can form on the surface of low-T\textsubscript{g} azo-polymers. The wave vector of formed gratings is parallel to the polarization direction of writing beam and multistate polarization storage can achieve in these materials [20].

In this experimental work we presented the light-induced birefringence (LIB), two beams and self induced SRG formation on the methylacrylate azo-polymer films. Our goal was to investigate the influence of material structures on these optical effects.

II. EXPERIMENTS, RESULTS AND DISCUSSIONS

A. Materials

In this work methylacrylate polymers with photochromic side chains, derivatives of azobenzene containing heterocyclic sulfonamide moieties, were used. The maximum absorbance wavelength and dipole moments of side chain units are presented in Table 1. Dipole moments have been calculated by Gaussian RHF/3-21g for isolated molecule [21]. The structural formulas are given in Fig. 1.

Table 1: Wavelength of maximum absorbance $\lambda_{\text{max}}$ and dipole moment $\mu$ of chromophores

<table>
<thead>
<tr>
<th>Monomer</th>
<th>$\lambda_{\text{max}}$ (nm)</th>
<th>$\mu / 10^{-30}$ (C m)</th>
<th>trans - cis</th>
</tr>
</thead>
<tbody>
<tr>
<td>1I</td>
<td>440</td>
<td>34.10</td>
<td>27.84</td>
</tr>
<tr>
<td>2I</td>
<td>446</td>
<td>35.29</td>
<td>17.53</td>
</tr>
<tr>
<td>3I</td>
<td>450</td>
<td>34.65</td>
<td>13.28</td>
</tr>
<tr>
<td>2M</td>
<td>454</td>
<td>29.31</td>
<td>14.14</td>
</tr>
</tbody>
</table>

The monomers of the methylacrylate type contained aliphatic spacers (1,2,3I) of different length between chromophoric and methylacrylic groups. These monomers were copolymerized with butyl 2-methylacrylate (MB) and 2-ethylhexyl acrylate (AI) to get copolymers containing various chromophoric units such as MB1I, MB2I, MB3I, AI2I and AI2M. Preparation of these polymers is described elsewhere [22]. Glass transition temperature, wavelength of maximum absorbance and absorbance at the working wavelength of the polymers have been shown in Table 2.

Table 2: Glass transition temperature T\textsubscript{g}, wavelength of maximum absorbance $\lambda_{\text{max}}$ and absorbance at 488 nm of azo-polymers.

<table>
<thead>
<tr>
<th>Polymer</th>
<th>T\textsubscript{g} (°C)</th>
<th>$\lambda_{\text{max}}$ (nm)</th>
<th>$A_{488}$</th>
</tr>
</thead>
<tbody>
<tr>
<td>MB1I</td>
<td>86.2</td>
<td>433</td>
<td>1.3</td>
</tr>
<tr>
<td>MB2I</td>
<td>71.1</td>
<td>438</td>
<td>1.33</td>
</tr>
<tr>
<td>MB3I</td>
<td>71.5</td>
<td>435</td>
<td>1.55</td>
</tr>
<tr>
<td>AI2I</td>
<td>57.5</td>
<td>435</td>
<td>1.13</td>
</tr>
<tr>
<td>AI2M</td>
<td>53</td>
<td>445</td>
<td>1.42</td>
</tr>
</tbody>
</table>

Thin films of polymers on glass substrates were prepared by spin-coating 50 mg/ml polymers solutions in TetrahydroFuranne (THF) solvent. Using a profilier, Dektak-6M Stylus Profiler, thickness of the thin films were measured about $\sim$ 0.45 $\mu$m. Fig. 2 shows the absorbance of the polymer films. The $\lambda_{\text{max}}$ = 488 nm laser line of a continuous argon ion laser was used as a pump beam for light-induced birefringence and grating formation in thin films.

B. Light-induced birefringence experiments

The experimental setup for measuring light-induced birefringence is shown in Fig. 3.

An Ar ion laser (488 nm) is used as pump beam inside the absorption band of polymers, and a He-Ne laser (633 nm) is used as a probe beam. The transmission of the He-Ne laser through the film placed between crossed polarizers is recorded by a photodiode as a function of time after irradiation with the...
pump beam polarization set at 45° angle with respect to the probe beam polarization. The pump induces optical anisotropy in the film.

The UV-vis spectra of materials is given by:

$$\Delta n = \frac{\lambda_o}{\pi d} \arcsin \left( \frac{I(t)}{I_o} \right),$$  \hspace{1cm} (1)

where $\lambda_o$, $d$, $I(t)$ and $I_o$ are wavelength of the probe beam, thickness of the film, intensity of transmitted and incident probe beam, respectively.

Figure 4 shows a typical birefringence excitation - relaxation sequence. The birefringence signal increase rapidly and reaches saturation after the pump beam is turned on at point A. It decreases and reaches to a constant value that will be kept constant for a long time in the dark after the writing beam is then turned off at point B. The dynamics of birefringence decay, in the absence of pump beam, have been studied by biexponential function for the assumption of fast and slow decays [23].

The biexponential function is

$$\Delta n(t) = A + B \exp(-\tau_1 t) + C \exp(-\tau_2 t)$$ \hspace{1cm} (2)

where $A$ is the birefringence conserved for a long times, $\tau_1$, $\tau_2$ are the relaxation rates with amplitudes of $B$ and $C$ respectively. The normalized parameters obtained by fitting equation 2 to the experimental results summarized in Table 3. The results show that for low-Tg azo-polymers, saturated value of $\Delta n_s$ and stable values of the photoinduced birefringence $A$ decrease with the decrease of Tg. The relaxation rates, $\tau_1$ and $\tau_2$ of the photoinduced birefringence increase with the decrease of Tg.

<table>
<thead>
<tr>
<th>Polymer</th>
<th>$A$</th>
<th>$B$</th>
<th>$C$</th>
<th>$\tau_1$ (1/s)</th>
<th>$\tau_2$ (1/s)</th>
<th>$\Delta n_s$</th>
</tr>
</thead>
<tbody>
<tr>
<td>MB1I</td>
<td>0.66</td>
<td>0.279</td>
<td>0.275</td>
<td>0.446</td>
<td>0.053</td>
<td>0.0051</td>
</tr>
<tr>
<td>MB2I</td>
<td>0.67</td>
<td>0.307</td>
<td>0.310</td>
<td>0.476</td>
<td>0.068</td>
<td>0.0052</td>
</tr>
<tr>
<td>MB3I</td>
<td>0.63</td>
<td>0.374</td>
<td>0.268</td>
<td>0.431</td>
<td>0.032</td>
<td>0.0048</td>
</tr>
<tr>
<td>AI2I</td>
<td>0.68</td>
<td>0.354</td>
<td>0.276</td>
<td>0.630</td>
<td>0.045</td>
<td>0.0045</td>
</tr>
<tr>
<td>AI2M</td>
<td>0.60</td>
<td>0.330</td>
<td>0.319</td>
<td>0.900</td>
<td>0.058</td>
<td>0.0038</td>
</tr>
</tbody>
</table>

The process is interpreted as trans–cis–trans isomerization and reorientation of the azobenzene derivatives. Many write – erase cycles can be achieved without significant
degradation. This shows that polymer films in question can be used for reversible optical storage purposes.

![Fig. 5](image)

**Fig. 5** Schematic diagram for the measurement of diffraction efficiency of the SRG in polymeric films. M$_1$ and M$_2$ are mirrors. The angle $\theta$ is 10°.

### C. SRG formation experiments

We checked the capability of polymers to make SRG. The gratings were optically inscribed onto the films with a single laser beam partly split by a mirror and reflected onto the film surface using the Lloyd mirror setup shown in Fig. 5.

![Fig. 6](image)

**Fig. 6** AFM profile of the formed SRG on the azo-polymer film.

The 488 nm line from an argon laser expanded to a diameter of 8 mm was used for writing. Grating inscription was monitored by measuring the growth of the first-order diffracted beam over time with a 5 mW, 633 nm He-Ne laser probe, in the transparency region of the material. We used orthogonally polarized beam configuration (right and left circular) for interfering beams. The probe beam was p-polarized. Efficiencies were measured as the percentage of first-order diffracted beam intensity to the transmitted light. The angle ($\theta$), as shown in Fig. 5, is maintained at $\sim 10^\circ$ to obtain a grating periodicity of $\Lambda \sim 1.4 \mu$m. The surface morphology of the samples was imaged with a Pico SPM from Molecular Imaging. Atomic force microscopy was performed in contact mode with a maximum scanning area of 6.5 x 6.5 $\mu$m (Fig. 6).

The diffraction efficiencies for polymers with different spacers (MB1I, MB2I, and MB3I) were presented in Fig. 7. By increasing the length of spacer, the diffraction efficiency was decreased.

![Fig. 7](image)

**Fig. 7** Diffraction efficiencies of SRG formed on the surface of azo polymer films with different chromophore length as a function of time.

Figure 8 shows diffraction efficiencies for two different azo-polymers with the same azo side chain (MB2I and AI2I). The result shows that for polymer with higher glass transition temperature (T$_g$), the diffraction efficiency is lower because of difference in diffusion coefficient [24].

Figure 9 shows the diffraction efficiency for polymers with different azo side chain (AI2I and AI2M). However, as the T$_g$ value of AI2I is higher than AI2M, the diffraction efficiency is higher for AI2I as compared with AI2M. It can be explain by the difference in the dipole moment of azo unit, the dipole moment of 2M is less than 2I and efficiency of light-matter interactions is lower.
Fig. 8 Diffraction efficiencies of SRG formed on the surface of azo polymer films with different Tg as a function of time.

Fig. 9 Diffraction efficiencies of SRG formed on the surface of azo polymer films with different chromophores as a function of time.

Fig. 11 presents the diffracted beam intensity as a function of time for different materials. The intensity rises over several tens of minutes and finally saturated. The rate of growth and maximum value of diffracted beam intensity depend on the material structure.

Figure 12 shows the influence of writing beam power on the grating formation process. In the case of MB2I (Fig. 12.a) for low powers, diffracted beam intensity rises and then saturated but for higher intensities, it increases, reaches to a maximum and then drops to some constant value. We think that the relaxation of diffracted beam intensity can be due to the reorientation of azo group or deformation of SRG [25]. Typically Fig. 12.b shows the influence of writing beam power for the other materials that used in this study (for example MB3I). The results show that by increasing the power of writing beam, the rate of growth is increased (Fig. 12.a-b). Figure 13 shows the typical AFM image of self-induced SRGs, the pitch of grating is around 800 nm.

D. Self-induced SRG formation

Our experimental setups are depicted in Fig. 10. Incoming light intensity is controlled by the power supply. Polarization direction of the laser beam is varied using a half-wave plate. Sample is set perpendicular to the incident laser beam. The size of the collimated laser beam impinging onto the polymer sample is controlled with a Kepler-type afocal system. Sample is irradiated with different polarizations using different laser beam intensities with a beam size of 4 mm diameter at 1/e². In order to monitor the formation of photoinduced SRG, the intensity of writing beam backward diffraction was measured by a photodiode.

Figure 12 shows the influence of writing beam power on the grating formation process. In the case of MB2I (Fig. 12.a) for low powers, diffracted beam intensity rises and then saturated but for higher intensities, it increases, reaches to a maximum and then drops to some constant value. We think that the relaxation of diffracted beam intensity can be due to the reorientation of azo group or deformation of SRG [25]. Typically Fig. 12.b shows the influence of writing beam power for the other materials that used in this study (for example MB3I). The results show that by increasing the power of writing beam, the rate of growth is increased (Fig. 12.a-b). Figure 13 shows the typical AFM image of self-induced SRGs, the pitch of grating is around 800 nm.
III. CONCLUSION

Five novel azo-polymers were studied. Light-induced birefringence studies showed that its saturation value, relaxation rates and stability depend on Tg of materials. Surface relief gratings and self-induced SRGs were inscribed on these azo-polymers. SRG formation on azo-polymer films and its diffraction efficiencies depend on both polymer main chain and chromophore structure. The results showed that these materials are suitable for all applications related to SRGs. The self-induced SRGs will provide for these polymers some new applications.

ACKNOWLEDGMENT

This work has been supported partially by Center for International Research and Collaboration (ISMO) and French Embassy in Tehran and by the research grant of the University of Tabriz.

REFERENCES


THIS PAGE IS INTENTIONALLY LEFT BLANK.